Supporting Information for

Conductive Block Copolymers Integrated into Polynorbornene-Derived Scaffolds

Hyun A Kang, Hindy E. Bronstein and Timothy M. Swager*

Department of Chemistry, Massachusetts Institute of Technology,
77 Massachusetts Avenue, Cambridge, Massachusetts 02139

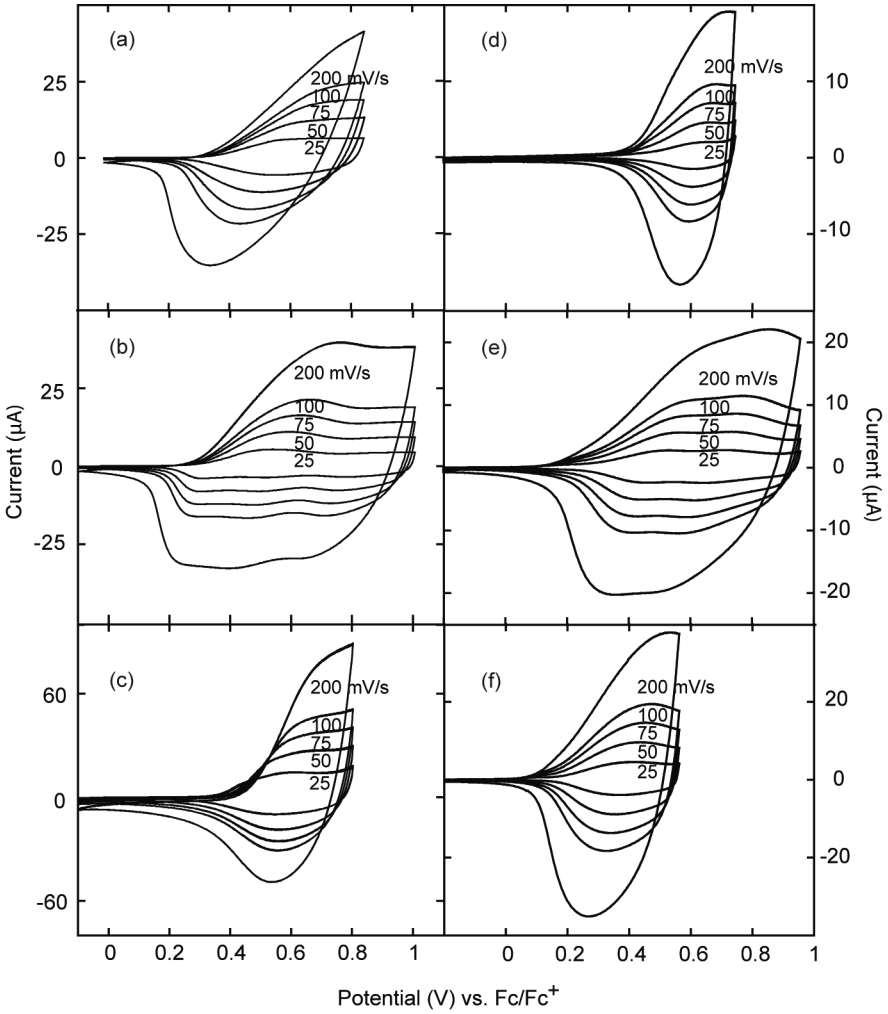

Figure S1. CVs of monomers (**4** (a), **5** (b) and **6** (c)) on Pt button electrodes in 0.1 M $TBAPF_6$ of CH_3CN solution, and homopolymers (**Poly(4)** (d), **Poly(5)** (e) and **Poly(6)** (f)) on Pt button electrodes in 0.1 M $TBAPF_6$ of CH_2Cl_2 solution. Polymer film CVs obtained at 25 - 200 mV/s.

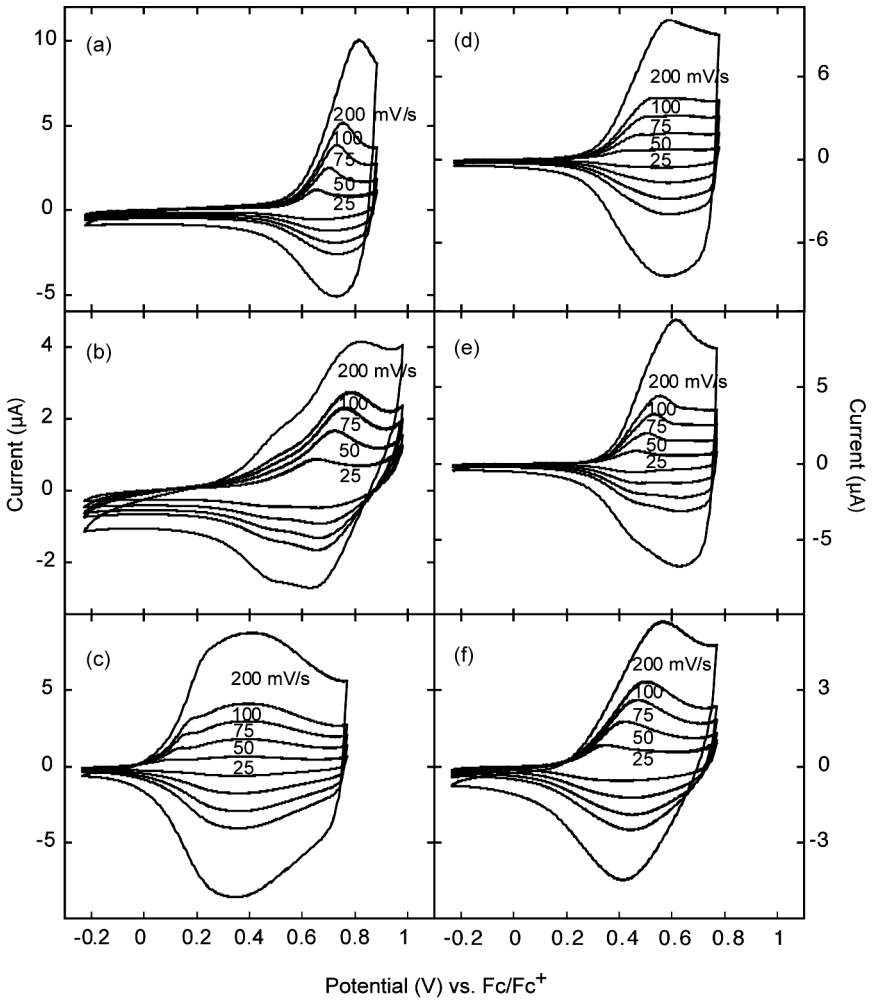

Figure S2. CVs of block copolymers (**BCP4** (a), **BCP5** (b) and **BCP6** (c)), and hydrogenated block copolymers (**BCP4** (d), **BCP5** (e) and **BCP6** (f)) on Pt button electrodes in 0.1 M $TBAPF_6$ of CH_2Cl_2 solution. Polymer film CVs obtained at 25 - 200 mV/s.

Table S1. Molecular weight of block copolymers from GPC

Polymer	Mn (first block)	Mn (total)
BCP1	53,700	58,600
BCP2	49,000	53,700
BCP3	55,700	69,200
BCP4	49,000	59,300
BCP5	43,500	47,800

BCP6	44,100	53,800